

UNITED STATES PATENT AND TRADEMARK OFFICE



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/838,126	04/20/2001	David Trost	005524 USA/PDC/WF/DB	8689	
32588 75	590 11/25/2002				
	ATERIALS, INC.		EXAMI	EXAMINER	
2881 SCOTT BLVD. M/S 2061 SANTA CLARA, CA 95050			LATTIN, CHRI	LATTIN, CHRISTOPHER W	
			ART UNIT	PAPER NUMBER	
			2812		
			DATE MAILED: 11/25/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

_	Application No.	Applicant(s)			
, a		i stringing, Ko			
	09/838,126	TROST ET AL.			
Office Action Summary	Examiner	Art Unit			
	Christopher W Lattin	2812			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).					
Status 1) Responsive to communication(s) filed on					
	action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. Disposition of Claims					
4)⊠ Claim(s) <u>1-14 and 23-30</u> is/are pending in the application.					
4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1-14 and 23-30</u> is/are rejected.					
7) Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or election requirement.					
Application Papers					
9) The specification is objected to by the Examiner.					
10) The drawing(s) filed on is/are: a) accept					
Applicant may not request that any objection to the					
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.					
If approved, corrected drawings are required in reply to this Office action.					
12) ☐ The oath or declaration is objected to by the Examiner.					
Priority under 35 U.S.C. §§ 119 and 120					
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).					
a) All b) Some * c) None of:					
1. Certified copies of the priority documents have been received.					
2. Certified copies of the priority documents have been received in Application No					
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).					
a) The translation of the foreign language provisional application has been received. 15) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.					
Attachment(s)					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 5.		y (PTO-413) Paper No(s) Patent Application (PTO-152)			

Application/Control Number: 09/838,126

Art Unit: 2812

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-14 and 23-30 are rejected under 35 U.S.C. 102(b) based upon the offer for sale of the invention. Exhibit A evidences a sale on June 24, 1999. The quote did not detail the claimed method nor any manner in which Etec would control such a method, and merely required that process results of the electron beam lithography machine as a whole be reported. Such an offer for sale does not qualify as experimental use and the MEBES system is therefore barred as on sale more than one year prior to filing in the U.S.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-14 and 23-30 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lee (U.S. Patent 6,130,490) in view of McCullough (U.S. Patent 6,445,439).

Lee teaches a method of manipulating a reticle within an evacuated chamber of an electron beam lithography apparatus, but fails to teach thermal management of the reticle by placing it in close proximity to a heated body. McCullough teaches a method of thermal management by placing a reticle in close proximity to a heated body. It would have been obvious to one skilled in the art at the time of the invention to perform the method of thermal management taught by McCullough of placing a reticle in close proximity to a heated body with the method taught by Lee in order reduce distortions that occur during electron beam lithography.

Official Notice is taken that although the particular temperature and pressure ranges are not specifically mentioned in the applied references, such parameters would have been obvious. "Under some circumstances [process ranges] may impart patentability to a process if the particular ranges claimed produce a new and unexpected result which is different in kind and not merely degree from the results of the prior art... such ranges are termed "critical ranges and the applicant has the burden of proving such criticality... More particularly, where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation." *In re Aller* 105 USPQ 233, 255 (CCPA 1955). See also *In re Waite* 77 USPQ 586 (CCPA 1948); *In re Scherl* 70 USPQ 204 (CCPA 1946); *In re Irmscher* 66 USPQ 314 (CCPA 1945); *In re Norman* 66 USPQ 308 (CCPA 1945);

Application/Control Number: 09/838,126 Page 4

Art Unit: 2812

In re Swenson 56 USPQ 372 (CCPA 1942); In re Sola 25 USPQ 433 (CCPA 1935); In

re Dreyfus 24 USPQ 52 (CCPA 1934).

Conclusion

The prior art made of record and not relied upon is considered pertinent to

applicant's disclosure. Feldman et al. (U.S. Patent 6,404,481), Samuels (U.S. Patent

5,304,441), and Chilese et al. (U.S. Patent 6,424,879) teach methods of controlling or

correcting for thermal aberrations that in reticles as the result of thermally related

processing steps.

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Christopher Lattin whose telephone number is (703)

305-3017. The examiner can normally be reached Monday through Friday from 8:00

A.M. to 5:00 P.M. If attempts to reach the examiner by telephone are unsuccessful, the

examiner's supervisor, John Niebling, can be reached at (703) 308-3325. The fax

numbers for this Group are (703) 872-9318 for responses to non-final actions and (703)

872-9319 responses to final actions. Any inquiry of a general nature or relating to the

status of this application or proceeding should be directed to the Group receptionist

whose telephone number is (703) 308-0956.

CWL 2

November 19, 2002

John F. Niebling

Supervisory Patent Examiner

Technology Center 2600